



PATENT

In re Patent of:

Shinichi SHIMA

Application No.: 09/986,958

Filed: November 13, 2001

For: EXPOSURE APPARATUS, METHOD OF)
MANUFACTURING SEMICONDUCTOR DEVICES, :
SEMICONDUCTOR MANUFACTURING PLANT,)
METHOD OF MAINTAINING EXPOSURE :
APPARATUS, AND POSITION DETECTOR)

U.S. Patent No. 6,822,727 B2

Issued: November 23, 2004

Examiner: H. Nguyen

Group Art Unit: 2851

February 28, 2005

Certificate
MAR 03 2005
of Correction

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450
Attention: Certificate of Correction Branch

REQUEST FOR
CERTIFICATE OF CORRECTION
UNDER RULES 322 AND 323

Sir:

Patentee requests that a Certificate of Correction be issued by the Patent and Trademark Office due to errors which appear in the printed patent as a result of Patent and Trademark Office mistakes and mistakes of a minor nature which are not the fault of the Patent and Trademark Office. A Certificate of Correction form, in duplicate, is enclosed.

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Accompanying this letter is a check for \$100.00 to cover the statutory fee for such Certificate of Correction. Any additional fee required by this paper may be charged to Deposit Account No. 06-1205. A duplicate of this paper is enclosed for that purpose.

Patentee's undersigned attorney may be reached in our Washington, D.C. Office by telephone at (202) 530-1010. All correspondence should continue to be directed to our below-listed address.

Respectfully submitted,



Attorney for Patentee
Steven E. Warner
Registration No. 33,326

FITZPATRICK, CELLA, HARPER & SCINTO
30 Rockefeller Plaza
New York, New York 10112-3801
Facsimile: (212) 218-2200
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UNITED STATES PATENT AND TRADEMARK OFFICE
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PATENT NO. : 6,822,727 B2

DATED : November 23, 2004

INVENTOR(S): Shinichi SHIMA

Page 1 of 8

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Line 52, "that LW2" should read -- that length LW2 --.

COLUMN 19:

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Line 49, "of large" should read -- of a large --.

Line 59, "of Semiconductor" should read -- of a Semiconductor --.

Line 61, "eg., (semiconductor)" should read -- (e.g., semiconductor --.

COLUMN 20:

Line 9, "eg., (lithographic)" should read -- (e.g., lithographic --.

Line 12, "etc.)" should read -- etc.), --.

Line 13, "eg., (assembly)" should read -- (e.g., assembly --.

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COLUMN 21:

Line 15, "manufacturing" should read -- the manufacturing -- and "of semiconductor" should read -- of a semiconductor --.

Line 16, "devices)." should read -- device). --.

Line 27, "maker **210**, resist" should read -- maker **210**, a resist --.

Line 28, "and thin-film" should read -- and a thin-film --.

Line 30, "for remote" should read -- for performing remote --.

COLUMN 22:

Line 2, "vender," should read -- vendor, --.

Line 9, "Manufacturing Semiconductor" should read -- Manufacturing a Semiconductor --.

Line 27, "and durability" should read -- and a durability --.

COLUMN 24:

Line 15, "detections" should read -- detection --.

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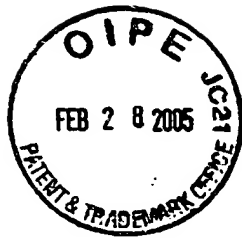
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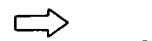
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Line 27, "and durability" should read -- and a durability --.

COLUMN 24:

Line 15, "detections" should read -- detection --.

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